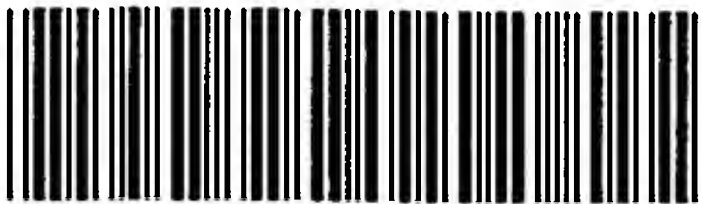


<div>Search Notes</div> <div></div>	Application/Control No.	Applicant(s)/Patent under Reexamination	
	10/709,534	JONES ET AL.	
	Examiner	Art Unit	
	W. David Coleman	2823	

SEARCHED			
Class	Subclass	Date	Examiner

INTERFERENCE SEARCHED			
Class	Subclass	Date	Examiner

SEARCH NOTES (INCLUDING SEARCH STRATEGY)		
	DATE	EXMR
EAST ver. 2.0.1 text search USPGPUBS; USPAT; EPO; JPO; Derwent; IBMTDB; STN; IEEE	9/5/2005	WDC
Applicants form a coblat capping layer over a cobalt/titanium nitride layer CMOS to reduce stress	9/5/2005	WDC